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DATE MAILED: 10/17/2006

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/671,608	09/29/2003	Tetsuo Ono	520.38979CX1	8510
20457	7590 10/17/2006		EXAM	INER
ANTONELLI, TERRY, STOUT & KRAUS, LLP 1300 NORTH SEVENTEENTH STREET			AHMED, SHAMIM	
SUITE 1800	SEVENTEENTH STREE.	,	ART UNIT	PAPER NUMBER
ARLINGTON	, VA 22209-3873		1765	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)	_ 			
Office Action Summary		10/671,608	ONO ET AL.				
		Examiner	Art Unit				
		Shamim Ahmed	1765				
Period fo	The MAILING DATE of this communication app or Reply	pears on the cover sheet with the	correspondence address				
WHIC - Exte after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DANSIONS of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. Operiod for reply is specified above, the maximum statutory period were to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be the state of	N. imely filed In the mailing date of this communication ED (35 U.S.C. § 133).				
Status							
1)[Responsive to communication(s) filed on 04 A	<u>ugust 2006</u> .	·				
2a) <u></u>	· · · · · · · · · · · · · · · · · · ·	action is non-final.					
3)	Since this application is in condition for allowar	nce except for formal matters, pr	osecution as to the merits is	3			
	closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 11, 4	53 O.G. 213.				
Disposit	ion of Claims						
4)⊠	Claim(s) 10,12 and 21-25 is/are pending in the	application.					
,	4a) Of the above claim(s) is/are withdrawn from consideration.						
5)⊠	Claim(s) <u>21 and 22</u> is/are allowed.						
6)⊠	Claim(s) 10,12 and 23-25 is/are rejected.						
7)	Claim(s) is/are objected to.	• :					
8)[Claim(s) are subject to restriction and/or	r election requirement.					
Applicat	ion Papers						
9)[7]	The specification is objected to by the Examine	r.					
-	The drawing(s) filed on is/are: a) acce		Examiner.				
,—	Applicant may not request that any objection to the	· · · · · · · · · · · · · · · · · · ·					
	Replacement drawing sheet(s) including the correct			d).			
11)[The oath or declaration is objected to by the Ex	caminer. Note the attached Office	e Action or form PTO-152.				
Priority (under 35 U.S.C. § 119						
	Acknowledgment is made of a claim for foreign ☐ All b) ☐ Some * c) ☐ None of:	priority under 35 U.S.C. § 119(a	a)-(d) or (f).				
	1. Certified copies of the priority documents	s have been received.					
	2. Certified copies of the priority documents	• •					
	3. Copies of the certified copies of the prior	•	ed in this National Stage				
	application from the International Bureau	, , , ,					
* (See the attached detailed Office action for a list	of the certified copies not receiv	ed.				
•							
Attachmen	• •	A) []	(DTO 442)				
	e of References Cited (PTO-892) te of Draftsperson's Patent Drawing Review (PTO-948)	4) Interview Summar Paper No(s)/Mail D					
3) 🔲 Infon	mation Disclosure Statement(s) (PTO/SB/08) or No(s)/Mail Date	5) Notice of Informal 6) Other:	Patent Application				

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DETAILED ACTION

Specification

Abstract

- 1. The abstract of the disclosure is objected to because it is too long and two paragraphs
- 2. Applicant is reminded of the proper language and format for an abstract of the disclosure.

The abstract should be in narrative form and generally limited to a single paragraph on a separate sheet within the range of 50 to 150 words. It is important that the abstract not exceed 150 words in length since the space provided for the abstract on the computer tape used by the printer is limited. The form and legal phraseology often used in patent claims, such as "means" and "said," should be avoided. The abstract should describe the disclosure sufficiently to assist readers in deciding whether there is a need for consulting the full patent text for details.

The language should be clear and concise and should not repeat information given in the title. It should avoid using phrases which can be implied, such as, "The disclosure concerns," "The disclosure defined by this invention," "The disclosure describes," etc.

Correction is required. See MPEP § 608.01(b).

3. The disclosure is objected to because of the following informalities: At the beginning of the specification, the continuing data needs to be updated such as the application Serial No. 09/646,012 is now US patent 6,660,647.

Appropriate correction is required.

Response to Arguments

4. Applicant's arguments with respect to claims 24-25 have been considered but are most in view of the new ground(s) of rejection.

Upon cancellation of claim 26, the 35 USC 103 (a) rejection is withdrawn.

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Double Patenting

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5. The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. A nonstatutory obviousness-type double patenting rejection is appropriate where the conflicting claims are not identical, but at least one examined application claim is not patentably distinct from the reference claim(s) because the examined application claim is either anticipated by, or would have been obvious over, the reference claim(s). See, e.g., *In re Berg*, 140 F.3d 1428, 46 USPQ2d 1226 (Fed. Cir. 1998); *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970); and *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) or 1.321(d) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent either is shown to be commonly owned with this application, or claims an invention made as a result of activities undertaken within the scope of a joint research agreement.

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

- 6. Claims 10,12,23-24 and 25 are rejected on the ground of nonstatutory obviousness-type double patenting as being unpatentable over claims 1,8 and 12 of U.S. Patent No. 6,660,647. Although the conflicting claims are not identical, they are not patentably distinct from each other because the invention in patent '647 broadly encompasses the claims in the instant invention.
- 7. As to claim 23, it would have been obvious the step of applying the radio frequency bias voltage on the sample board is divided into plural steps because the patent '647 controlling the periodic on-off of said bias voltage with a control frequency ranging from 100 Hz to 10 KHz.

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Allowable Subject Matter

8. Claims 21-22 are allowable over prior art.

9. The following is an examiner's statement of reasons for allowance:

Regarding claims 21-22, the cited prior art of record fails to disclose or suggest a surface processing method of a sample comprises a step of etching said n-type polycrystalline silicon and said p-N type polycrystalline silicon by introducing mixed gas containing fluorine and oxygen into said vacuum container while applying periodically on-off controlled radio frequency bias voltage, in combination with the rest of the limitations of claims 21-22.

Conclusion

10. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Cain (5,242,532) illustrates conventional plasma etching process control, wherein the RF power is controlled with the help of matching circuit.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shamim Ahmed whose telephone number is (571) 272-1457. The examiner can normally be reached on M-Thu (7:00-5:30) Every Friday Off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine G. Norton can be reached on (571) 272-1465. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Shamim Ahmed Primary Examiner Art Unit 1765

SA October 14, 2006